

Abstract Submitted  
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**Anomalous High Mobility in LaAlO<sub>3</sub>/SrTiO<sub>3</sub> Nanowires<sup>1</sup>**

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<sup>2</sup>C. Cen, S. Thiel, K. E. Andersen, C. S. Hellberg, J. Mannhart, and J. Levy, Nature Materials **7**, 2136 (2008).

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